

GEMOLOGICAL INSTITUTE

ELECTRONIC COPY

LABORATORY GROWN DIAMOND REPORT

PROPORTIONS

CLARITY CHARACTERISTICS

KEY TO SYMBOLS

Red symbols indicate internal characteristics. Green symbols indicate external characteristics.

| May 15, 2024 | | | | |
|--------------------------------|--------------------------|--|--|--|
| IGI Report Number | LG633409800 | | | |
| Description | LABORATORY GROWN DIAMOND | | | |
| Shape and Cutting Style | PRINCESS CUT | | | |
| Measurements | 7.80 X 7.56 X 5.33 MM | | | |
| GRADING RESULTS | | | | |
| Carat Weight | 2.81 CARATS | | | |
| Color Grade | 빈더찮던더군만 | | | |
| Clarity Grade | VS 1 | | | |
| ADDITIONAL GRADING INFORMATION | | | | |
| | | | | |

| Polish | EXCELLENT |
|----------------|------------------|
| Symmetry | EXCELLENT |
| Fluorescence | NONE |
| Inscription(s) | 1571 LG633409800 |

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process and may include post-growth treatment. Type IIa

72% --Medium 11% 누 70.5% 55.5% Pointed

LG633409800

Report verification at igi.org



Sample Image Used

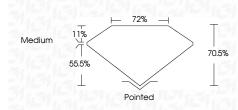
COLOR

| DEF | GHIJ | Faint | Very Light | Light |
|------------------------|--------------------------------|---------------------------|----------------------|------------|
| | WS ¹⁻² | VS ¹⁻² | SI ¹⁻² | 11-3 |
| Internally Flawless | Very Very Slightly Included | Very Slightly Included | Slightly Included | Included |
| | | | | |
| | | GEMOLOGIC | | |
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